

PHAROS

Modular-Design Industrial-Grade Femtosecond Lasers



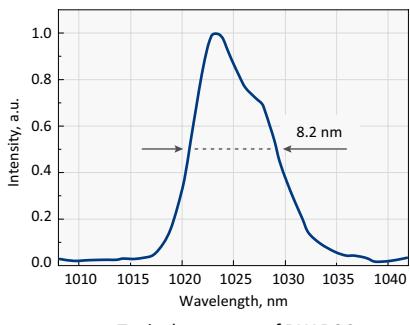
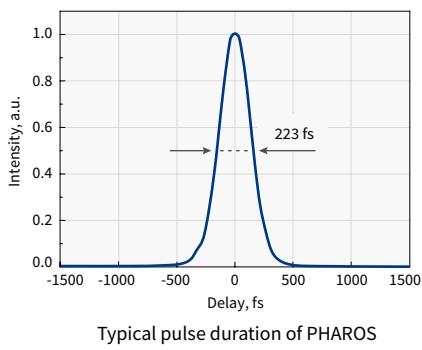
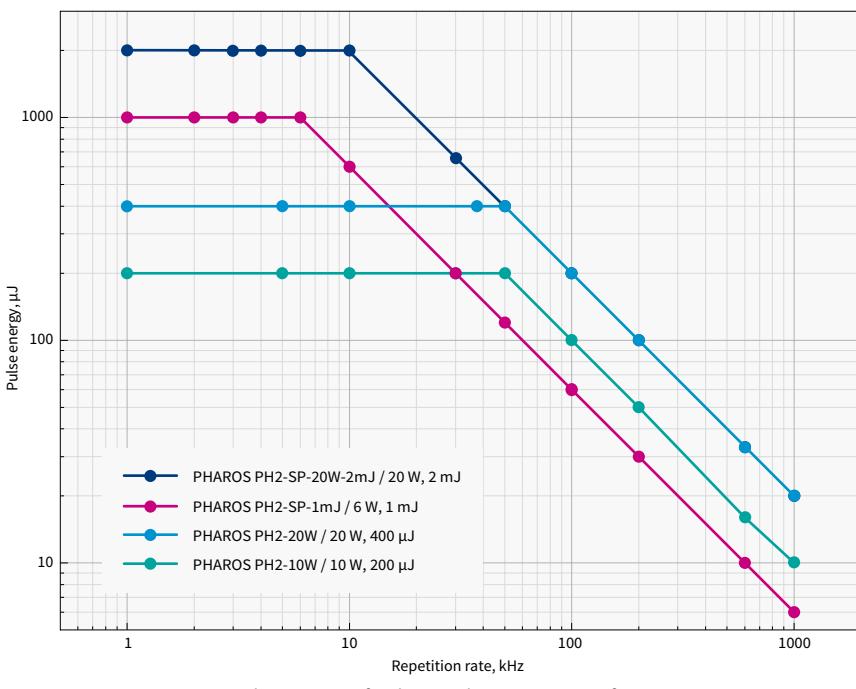
FEATURES

- 190 fs – 20 ps tunable pulse duration
- 2 mJ maximum pulse energy
- 20 W maximum output power
- Single-shot – 1 MHz repetition rate
- Pulse picker for pulse-on-demand mode
- Industrial-grade design
- Optional automated harmonic generator
- Optional CEP stabilization
- Optional repetition rate locking to an external source



PHAROS is a series of femtosecond lasers combining millijoule pulse energy and high average power. PHAROS features a mechanical and optical design optimized for both scientific and industrial applications. A compact, thermally-stabilized, and sealed design enables PHAROS integration into various optical setups and machining workstations. Diode-pumped Yb medium significantly reduces maintenance costs and provides a long laser lifetime, while the robust optomechanical design enables stable operation in varying environments.

The tunability of PHAROS allows the system to cover applications normally requiring multiple different laser systems. Tunable parameters include pulse duration (190 fs – 20 ps), repetition rate (single-shot – 1 MHz), pulse energy (up to 2 mJ), and average power (up to 20 W). A pulse-on-demand mode is available using the built-in pulse picker. The versatility of PHAROS can be extended by a variety of optional modules.



SPECIFICATIONS

| Model ¹⁾ | PH2-10W | PH2-15W | PH2-20W | PH2-SP-1mJ | PH2-SP-20W-2mJ |
|---|---|--|--|-----------------------------------|----------------|
| OUTPUT CHARACTERISTIC | | | | | |
| Maximum output power | 10 W | 15 W | 20 W | 10 W | 20 W |
| Pulse duration ²⁾ | | < 290 fs | | | < 190 fs |
| Pulse duration tuning range | 290 fs – 10 ps (20 ps on request) | | | 190 fs – 10 ps (20 ps on request) | |
| Maximum pulse energy | 0.4 mJ | | 1 mJ | | 2 mJ |
| Repetition rate | | Single-shot – 1 MHz | | | |
| Pulse selection | | Single-shot, pulse-on-demand, any fundamental repetition rate division | | | |
| Center wavelength ³⁾ | | 1030 ± 10 nm | | | |
| Polarization | | Linear, horizontal | | | |
| Beam quality | TEM ₀₀ ; M ² < 1.2 | | TEM ₀₀ ; M ² < 1.3 | | |
| Beam diameter ⁴⁾ | 2.5 mm | | 2.9 mm | | 4.3 mm |
| Pulse-to-pulse energy stability ⁵⁾ | | RMS deviation ⁶⁾ < 0.5% over 24 h | | | |
| Long-term power stability | | RMS deviation ⁶⁾ < 0.5% over 100 h | | | |
| Beam pointing stability | | < 20 μrad/°C | | | |
| Pre-pulse contrast | | < 1 : 1000 | | | |
| Post-pulse contrast | | < 1 : 200 | | | |
| OPTIONAL EXTENSIONS | | | | | |
| Oscillator output | Optional. Contact sales@lightcon.com for more details or customized solutions | | | | |
| Typical output | 1 – 6 W, 50 – 250 fs, ≈ 1035 nm, ≈ 76 MHz; available simultaneously | | | | |
| Harmonic generator | Integrated, optional (see page 8) | | | | |
| Output wavelength | 515 nm, 343 nm, 257 nm, or 206 nm | | | | |
| Optical parametric amplifier | Integrated, optional (see page 15) | | | | |
| Tuning range | 320 – 10000 nm | | | | |
| BiBurst option | Tunable GHz and MHz burst with burst-in-burst capability, optional (see page 9) | | | | |
| GHz-Burst | | | | | |
| Intra burst pulse period ⁷⁾ | 200 ± 40 ps | | | | |
| Number of pulses, P ⁸⁾ | 1 ... 25 | | | | |
| MHz-Burst | | | | | |
| Intra burst pulse period | ≈ 15 ns | | | | |
| Number of pulses, N | 1 ... 9 (7 with FEC) | | | | |
| PHYSICAL DIMENSIONS | | | | | |
| Laser head (L × W × H) ⁹⁾ | 780 × 419 × 230 mm | | | | |
| Chiller (L × W × H) | 590 × 484 × 267 mm | | | | |
| 24 V DC power supply (L × W × H) ⁹⁾ | 280 × 144 × 49 mm | | | | |
| ENVIRONMENTAL & UTILITY REQUIREMENTS | | | | | |
| Operating temperature | 15 – 30 °C (air conditioning recommended) | | | | |
| Relative humidity | < 80% (non-condensing) | | | | |
| Electrical requirements | 100 V AC, 12 A – 240 V AC, 5 A; 50 – 60 Hz | | | | |
| Rated power | 1000 W | | | | |
| Power consumption | 600 W | | | | |
| Electrical requirements (chiller) | 100 – 230 V AC; 50 – 60 Hz | | | | |
| Rated power (chiller) | 1400 W | | | | |
| Power consumption (chiller) | 1000 W | | | | |

¹⁾ More models are available on request.

²⁾ Assuming Gaussian pulse shape.

³⁾ Precise wavelengths for specific models are available on request.

⁴⁾ FWHM, measured at laser output, using maximum pulse energy.

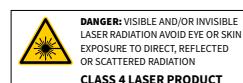
⁵⁾ Under stable environmental conditions.

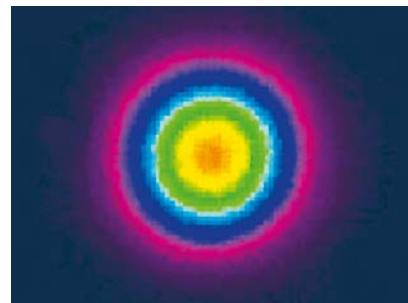
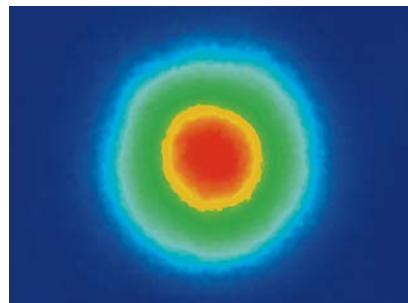
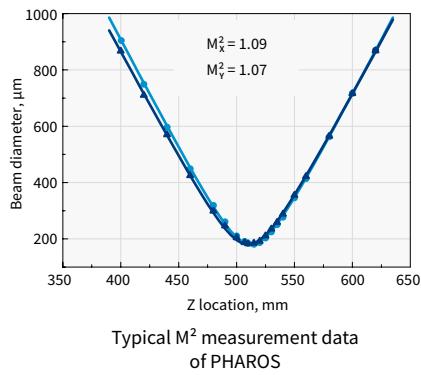
⁶⁾ Normalized to average pulse energy, NRMSD.

⁷⁾ Custom spacing is available on request.

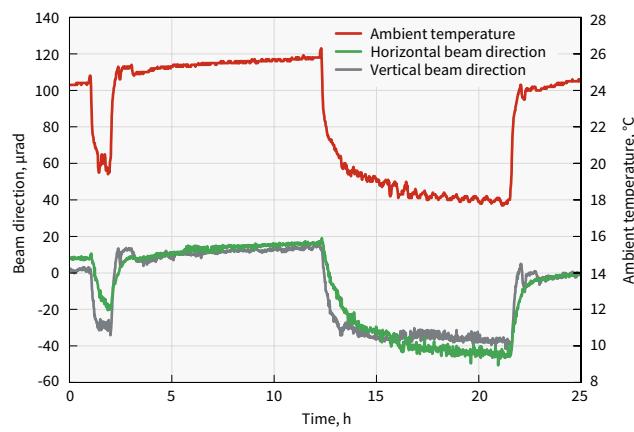
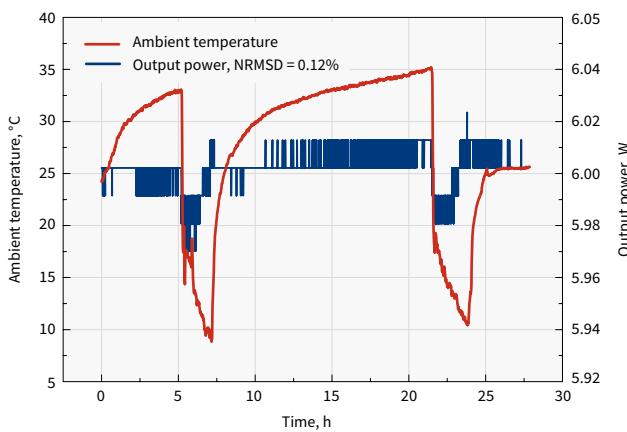
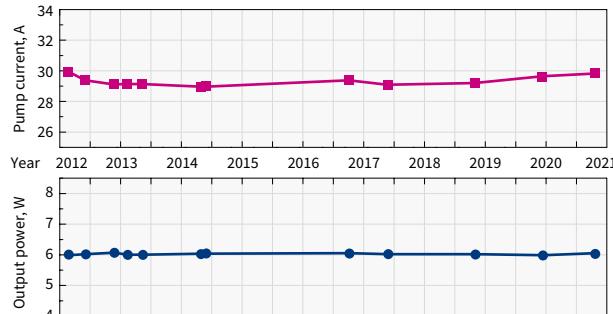
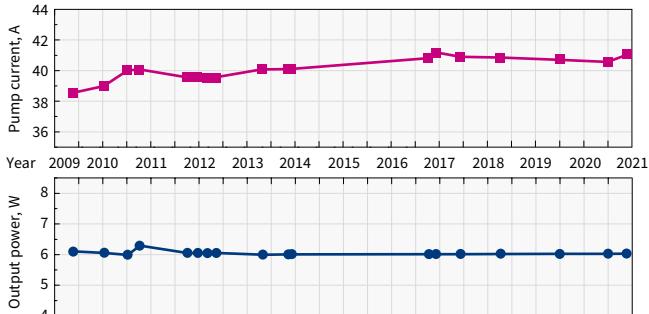
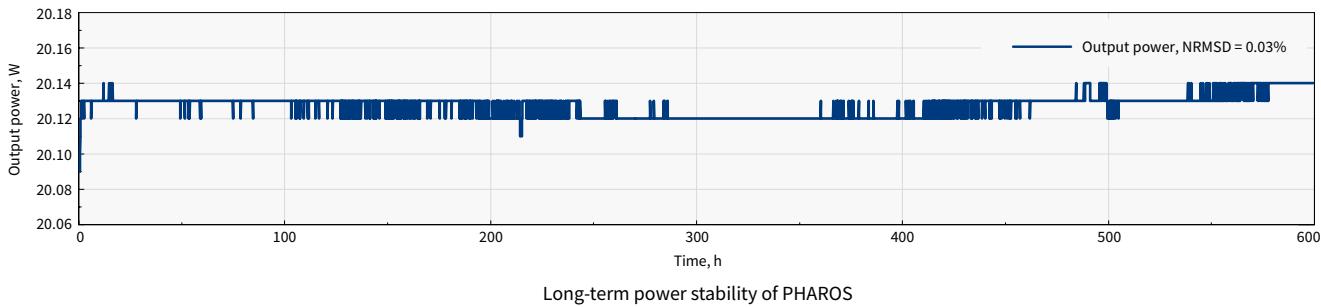
⁸⁾ Maximum number of pulses in a burst depends on the laser repetition rate. Custom number of pulses are available on request.

⁹⁾ Dimensions might increase for the lasers with integrated optional modules.





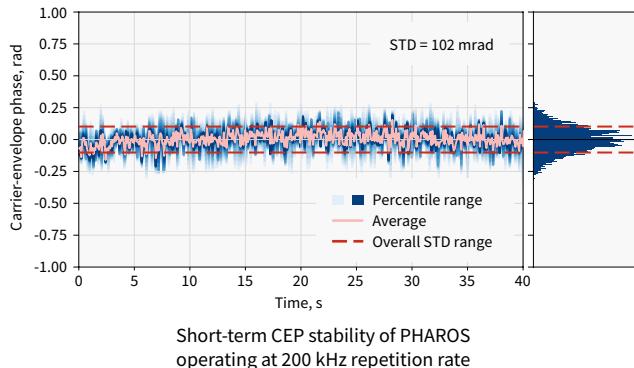
STABILITY MEASUREMENTS



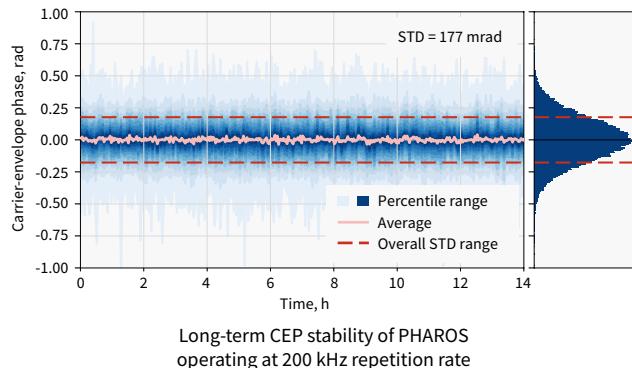
PHAROS output power and beam direction with power lock enabled, under harsh environmental conditions

CEP STABILIZATION

PHAROS lasers can be equipped with feedback electronics for carrier-envelope phase (CEP) stabilization of the output pulses. The carrier-envelope offset (CEO) of the PHAROS oscillator is actively locked to 1/4th of the repetition rate with a < 100 mrad standard deviation. The CEP stable pulses

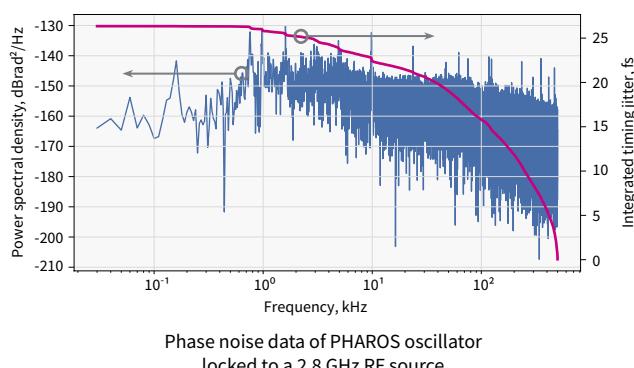


from the synchronized amplifier have a < 350 mrad standard deviation. The CEP drift occurring inside the amplifier and the user's setup can be compensated with an out of loop f-2f interferometer, which is a part of the complete PHAROS active CEP stabilization package.

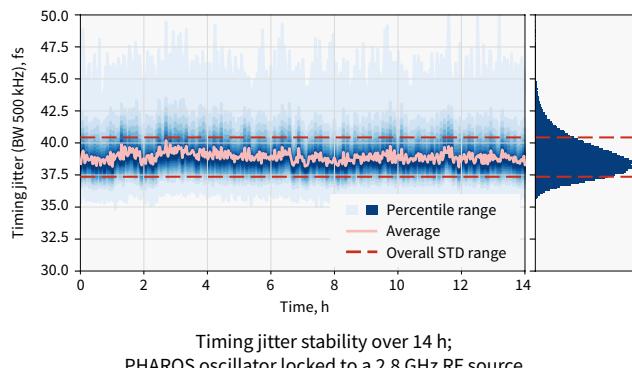


REPETITION RATE LOCKING

The oscillator of PHAROS laser can be customized for repetition rate locking applications. Coupled with the necessary feedback electronics, the repetition rate is synchronized to an external RF source using the two piezo stages installed inside the cavity.



The repetition rate locking system can assure an integrated timing jitter of less than 200 fs for RF reference frequencies larger than 500 MHz. Continuous phase shifting is available on request.



DRAWINGS

